

DARK CURRENTS

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Abstract

Dark current studies in the S-band structures and the DC electrodes have been primarily pointed at elucidating the causal relationships between the internally generated field emission currents and breakdown electric fields at high gradient. The experiment was focused to improve the material and fabrication method.

An S-band nose cone shape TM_{010} single standing-wave cavity was successfully operated surface electrical gradient up to 334 MV/m with 0.34 mA of peak dark current. A microscopic field enhancement factor of 37 obtained from the modified Fowler-Nordheim plots.

The DC electrodes using very clean SUS316L successfully obtained the maximum surface electrical field gradient of 34 MV/m with a 88 pA of very low dark currents at a gap width of 1 mm.

From these studies, it can mainly conclude that a magnitude of dark current is depend on a cleanliness of an inside of a structure, and the maximum electric field gradient is determined by shape of a structure geometry.

Introduction

This paper is an overall review of high gradient studies in the S-band structures and the DC electrodes carried out by author, some of our colleagues at KEK and T. Nakanishi group of Nagoya University. Also this work helped by G.A. Loew and J.W. Wang of SLAC and their colleagues.

A motivation of this work is to make clear an rf breakdown and a dark current phenomena at the breakdown surface electrical gradients as high as 200 MV/m; and determine the upper limit of the actual large scale accelerators.

For e^+e^- linear colliders with center of mass energies of 500 to 1000 GeV, the main linac will be operated with accelerating field gradients ranging from 40–100 MV/m. At this level, the corresponding peak surface electrical field gradient are in the range of 80–200 MV/m. At the present time however, most actual large electron accelerators run with accelerating gradients of around 10–17 MV/m. No laboratories have any experience yet with high gradient operations.

RF breakdown studies were started by SLAC and Varian to investigate the phenomena and to determine the upper limit of field gradients for rf structures [1, 2, 3].

In 1986, G.A. Loew and J.W. Wang of SLAC reported [1, 2, 4] their experimental results with a standing-wave cavity that could produce an equivalent traveling-wave accelerating gradient as high as 147 MV/m and a peak surface field in excess of 300 MV/m. However, at this high a gradient, a considerable amount of field emission and x-ray radiation was observed.

From these studies, many factors have been found which must be discussed with regard to rf breakdown phenomenon and dark currents: such things as the surface finish, microscopic dust, electron multiplication, materials and the vacuum condition inside the structure. However, the fundamental mechanisms involved in rf breakdown are not yet clearly understood well enough for application not only to the accelerating structure but also to photo-cathode rf guns with peak surface electrical field gradients in excess of 200 MV/m.

In 1987, KEK started a high gradient study in connection with plans for linear collider R&D in Japan. The experiments were done on four traveling-wave disk loaded structures, four TM_{010} standing-wave single cavities and DC electrodes.

From those experiments, the main conclusions obtained about the relations between rf breakdown and dark currents are the following:

1. The magnitude of the dark current depends on the cleanliness inside the structure,
2. It was shown conclusively that the maximum electrical field gradient is determined by the shape of the structure especially that of the coupler cavity,
3. Further the existence of microscopic voids between crystal grains even in very high quality OFHC copper was demonstrated, and it was shown that these voids are one of the reasons for dark currents [5].

In the following, the author would like to show the relationships between rf breakdown phenomena and dark currents based on our experimental results.

High Gradient Experiments at KEK

The work started with conventional disk loaded traveling-wave type structures, operating as close as possible to actual accelerator conditions. The following test structures were machined from high quality OFHC (Oxide Free High Conductivity) copper blocks with purity of ~99.996% and having typical chemical compositions as listed in Table 1.

Table 1
Chemical compositions of OFHC copper ($\times 10^{-4}\%$)

Pb	Zn	Bi	Cd	Hg	O ₂	P	S	Se	Te
1	<1	1	<1	<1	2	1	6	<1	<1
Sb	As	Mn	Sn	Fe	Ag	Ni			
2	1	1	2	2	4	<1			

Copper: HITACHI CLASS1 (>99.996%)

Test structures

All test structures were chosen to be of the 2/3 phase shift per cell. They were designed so as to test peak axial and surface electrical field gradients of up to 100 and 200 MV/m,

respectively. The main parameters of the structures are listed in Table 2.

Table 2
Main specifications of high gradient structures.

	5 cell structure	17 Cell structure
Frequency (MHz):	2856	
Phase shift per cell:	2 /3, C.I.	2 /3, C.G.
Structure length (cm):	17.5	59.5
Iris diameter (cm):	1.6	1.8998-1.590
Factor of merit Q:	13330	11600
Attenuation constant (μ sec):	0.702	0.48
Filling time (μ sec)	0.19	0.475
Surface gradient E_p (MV/m):	$18.84\sqrt{P_m}$ [MW]	$14.32\sqrt{P_m}$ [MW]
Surface finish at irises (μ m):	0.6	Conventional: 0.8 Clean: 0.8 Electroplated: 0.3

5 cell traveling-wave structure. For the first step, experiments were done on a small scale (five cells) traveling-wave, constant impedance (C.I.) type structure at S-band. It was manufactured by the usual methods and fabricated in the usual atmospheric environment (class 10000). The vacuum seal was made by an electroplated layer; no brazing process was necessary.

For this experiment, the maximum peak axial electrical field gradient and surface field gradient obtained was 104.5 and 209 MV/m, respectively. At this level, however, a large amount of dark current generated from the beam hole and rf breakdown was often observed coming from the structure.

From this experiment, it was found that reducing the dark current is more difficult than getting a high peak electrical field gradient on the conventional structure. However, as can be seen in Figure 1, the modified Fowler-Nordheim (F-N) plot gives us a hint towards the direction for the next step.

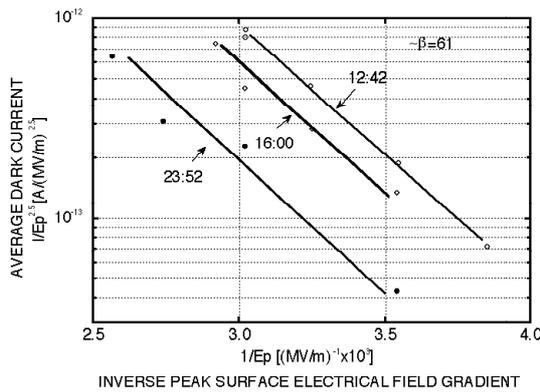


Fig. 1. Fowler-Nordheim plots at different times on the same day.

Three fitted F-N plots lines in Figure 1 come from measurements at different times on the same day. From this we can see that the quantity of dark current emitted decreases with rf processing time; but the microscopic field enhancement factor (β) does not depend on the rf processing time. This data suggests that we may have to separate the dark current from the rf breakdown phenomena, because one can guess that the

upper limit of the electrical field gradient mainly depends on the local β value; consider a simple geometry such as the electrical potential problem for two parallel plates.

17 cell traveling-wave structure. In the second step, the investigation was primarily aimed at elucidating the causal relationships between the internally generated dark currents and breakdown electrical field in high gradient accelerator structures.

Three structures were made to compare the maximum accelerating gradient and the amount of dark current emitted in the same experimental system [6].

Two structures were manufactured by a brazing method in a hydrogen furnace. The third was manufactured by the electroplating method. One of brazed structure was fabricated in the usual atmospheric environment (conventional structure); the other was carefully fabricated so as to be free from any contamination inside the structure (clean structure). The electroplated structure was fabricated in the usual atmospheric environment (electroplated structure).

During rf processing, the rf power (0.8 μ s pulses at 50 pps) applied to the structure was controlled by a program to keep the vacuum pressure below 1×10^{-8} Torr. The electrical field gradients were evaluated by measuring the energy spectrum of the dark currents generated by field emission from the structure. The performances achieved by the three structures are listed in Table 3.

Table 3
The performances achieved by the three structures.

		Conventional	Clean	Electro-plated
The maximum field gradient	MV/m	91	73	83.6
		44	57	53
Processing time	hours	800	200	200

The modified F-N plots for the three structures are shown in Figure 2.

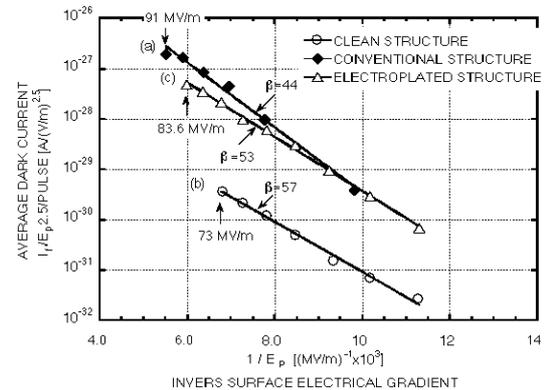


Fig. 2. Modified Fowler-Nordheim plots for three 60 cm-long traveling-wave structures.

As can be seen in Figure 2, the three F-N lines have almost same β values and the amount of dark current from the clean structure is an order of magnitude lower than that of the conventional and electroplated structures. The point to consider is that the only difference between the conventional and clean

structure is the amount of contamination on the structure surface. Thus, it can be concluded that a reduction in contamination could drastically reduce the dark current and that the upper limit to the electrical field gradient is determined by other factors.

In this experiment, both the input and output couplers of the clean structure had protruding areas (bumps) on the axis at each end cavity wall. These areas, with heights of a few mm and diameters of 1 cm, were caused by the rf tuning process. The effects can be seen in Figure 3, where in the energy spectrums of the emitted dark currents at each gradient, there is a narrow peak appearing in the energy range of 3 to 5 MeV and a broad peak appearing at around the maximum energy. Both of these features were caused by continuous rf breakdown at both bumps. After 200 hours of rf processing, the coupler cavities were examined and it was found that the top of the down-stream bump was melted by the continuous rf breakdown.

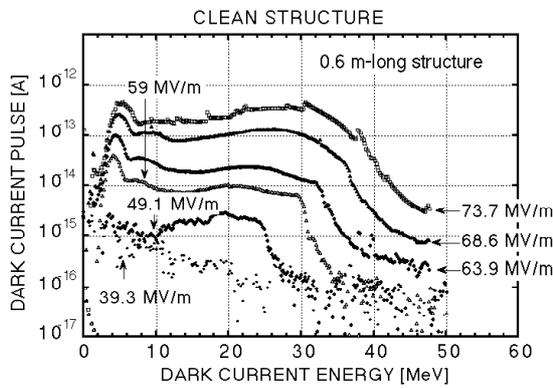


Fig. 3. Dark current energy spectrum of the clean structure.

This is the main reason why the clean structure did not achieve the highest electrical field gradient of the three structures. On the other hand, the Figure 4 shows that the electroplated structure did not have a clear peak in the dark current spectrum at any electrical field gradient. While even the electroplated structure has large amount of dark current, the maximum axial electrical field gradient achieved, up to 83.6 MV/m, is higher than the clean structure gradient of 73 M/m.

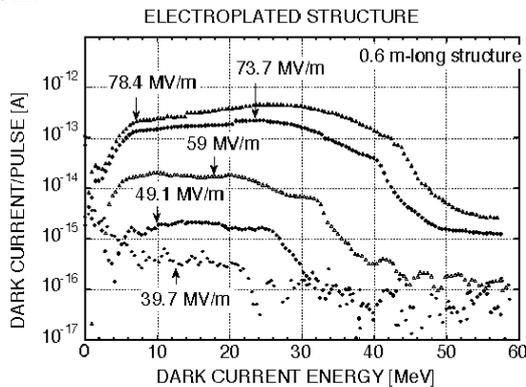


Fig. 4. Dark current energy spectrum of the electroplated structure.

TM₀₁₀ standing-wave single cavities. After the first half of the second experimental stage, it was decided to try some experiments to make clear the rf breakdown and dark current phenomena in a high gradient structure.

Four TM₀₁₀ single cavities were made to study the effects of fabrication methods such as using a pure water rinsing process and fabrication in a very high quality clean room (class 1), using low secondary electron emission coefficient Titanium (Ti) material and reducing the micro-pores of the OFHC copper by Hot Isostatic Pressing (HIP).

Three cavities with very simple pill box shapes all of the same dimension were designed so as to obtain surface electrical peak fields in excess of 100 MV/m at an input peak rf power of 5 MW. The main electrical parameters and cavity dimensions are listed in Table 4 and shown in Figure 5.

Table 4
The specifications for the three TM₀₁₀ cavities.

	Conventional	Clean	Electroplated
Frequency (MHz):	2854.5	2851.4	2852.3
Structure length (cm):	3.0		
Iris diameter (cm):	2.0		
Factor of merit Q:	13200	14090	8650
Surface gradient (MV/m):	$146\sqrt{P_{in}[\text{MW}]}$	$149\sqrt{P_{in}[\text{MW}]}$	$123\sqrt{P_{in}[\text{MW}]}$
Surface finish at irises (μm):	0.1	0.1	Copper: 0.1 Ti: 0.8
Clean room quality:	10000	1 ⁽¹⁾	10000
Rinsing solvent	Acetone	UPW ⁽²⁾	Acetone

- 1) Particles per cubic feet (>0.1 μm)
- 2) UPW: Ultra Pure Water (>18.2 M-Ohm* cm)

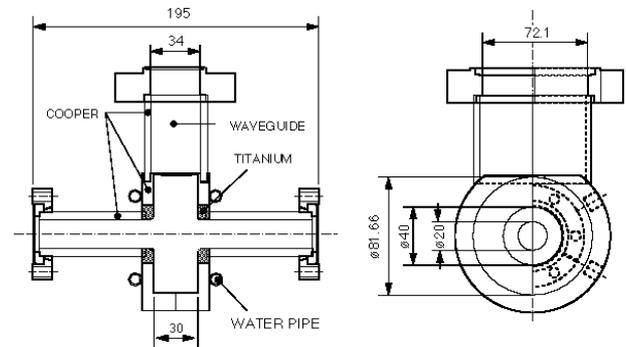


Fig. 5. Three TM₀₁₀ cavity dimensions. Only the Ti bounded cavity has Ti blocks around the beam holes.

A conventional cavity was fabricated by the usual methods in a class 10000 room and used as a reference to compare the quantity of dark current with the other two specially processed clean and Ti bounded HIP cavities.

The clean cavity was rinsed with ultra pure water (>18.3 M-Ohm cm) at end of manufacture and fabricated very carefully in a class 1 clean room to avoid contamination during the final assembly.

The composite material cavity is composed of two materials, OFHC and Titanium (Ti). Ti blocks were attached around the beam holes by using a diffusion bond with HIP procedure as shown in Figure 5. This type of cavity is advantageous in reducing dark current, since the secondary field emission coefficient of Ti is less than unity (~0.9).

HIP is a thermomechanical forging method that makes using of a high gas pressure ($\sim 1200 \text{ kgf/cm}^2$) at high temperature ($\sim 850^\circ\text{C}$). Even in very high quality forged OFHC copper, there generally are some number of micro-pores the size of a few μm each at grain boundaries. These pores will be one of main sites for contamination inside the structure because machine oils trapped in them will be carbonized after the brazing process. The micro-structures of forged OFHC copper and HIP processed OFHC copper samples are shown in Figure 6. The photographs clearly shows that forged OFHC copper has micro-pores between the gains and these micro-pores disappeared in the HIP processed OFHC copper [5].

High gradient experiments on the three cavities were done on a test stand to make relative comparisons in the amount of dark current.

Two simple Faraday cup detectors (FD) were used to measure the dark current. One FD mounted just to the left of the straight beam line was used for the F-N plots. The other was located on the right side with a 90 degree bending magnet and used to measure the dark current energy spectrum. The vacuum status is very important in ascertaining the surface cleanliness inside the cavity. The vacuum level was monitored with B-A and cold-cathode gauges. Partial vacuum pressure was measured with a residual gas analyzer. The total base pressure of the high gradient test stand reached $\sim 1 \times 10^{-10}$ Torr after baking at 200°C for 100 hours. It is necessary to observe the details of the residual gas mass spectrums for each of the cavities.

The conventional cavity, clean cavity and Ti bonded cavity produced maximum surface gradients of 134 MV/m, 146 MV/m and 156 MV/m, respectively. In this experiment the maximum surface electrical gradient of three cavities was limited by the available klystron peak rf power. Figure 7 shows the F-N plot of three cavities at the end of the rf processing time. As can be seen in Figure 7, the three F-N lines have almost the same slope ($\beta = 50\sim 59$) and the amount of dark current from the clean and Ti bonded HIP processed cavities are one order of magnitude lower than that of the conventional cavity. From the results shown in Figure 6, it can be seen clearly that cleanliness is essential in reducing the dark current. The low secondary electron coefficient of Ti is also effective in reducing the dark current; this will be useful in rf gun applications.

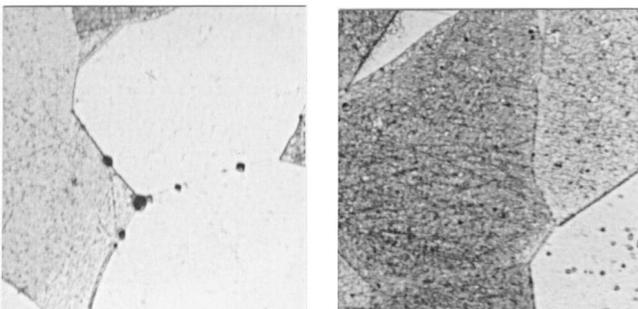


Fig. 6. Optical micrographs showing forged OFHC copper (left) and HIP-OFHC copper (right). [HIP parameters: temperature 850°C and isostatic pressure 1200 kgf/cm^2].

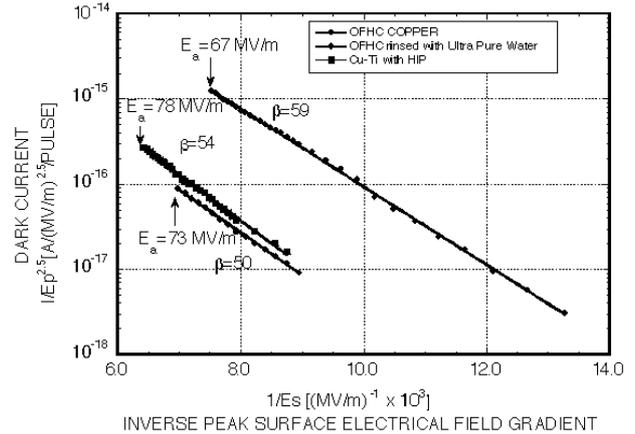


Fig. 7. Modified Fowler-Nordheim plots for the three differently processed cavities.

Figure 8 and 9 shows the mass spectra of the residual gases from the conventional and clean cavities at each surface electrical gradient level. As can be seen in Figure 8, three high peaks appeared showing H_2 , CO and CO_2 in the mass spectrums. CO and CO_2 molecules are typically caused by the impurities and contamination on the inner surface of the cavity. These two molecules are also very dangerous for a semiconductor photo-cathode material such as GaAs. On the other hand, the clean cavity in Figure 9 shows that the mass spectrum amplitudes do not depend on the surface electrical field gradient since only very small CO and CO_2 responses were observed. The total amount of residual gas in the clean cavity was smaller than that of the conventional cavity even at the highest 140 MV/m surface electrical gradient. These experimental results show again that the amount of dark current strongly depend on the cleanliness inside the cavity.

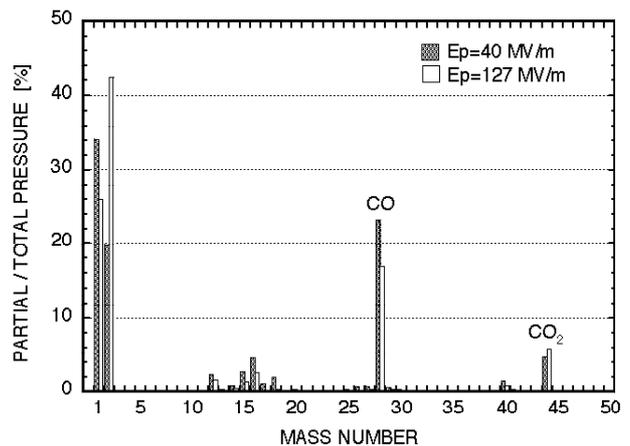


Fig. 8. Residual gas mass spectrum of the conventional cavity during rf power tuning.

A nose cone shaped cavity was used to determine the upper limit of surface electrical field gradient on the S-band cavity for an rf gun. The maximum electrical surface gradient was designed so as to obtain up to 350 MV/m at a peak input rf power of 5 MW.

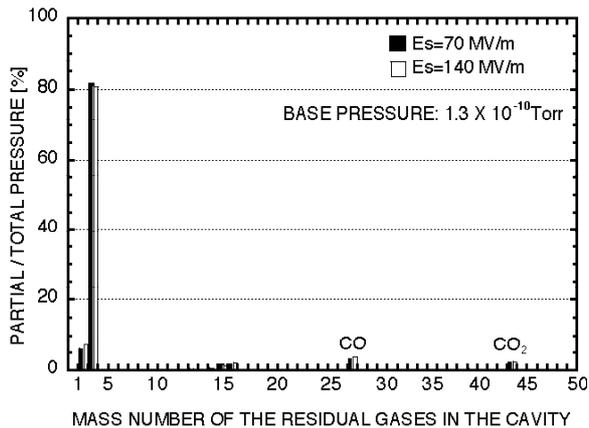


Fig. 9. Residual gas mass spectrum of the clean cavity during rf power tuning.

The cavity was rinsed with pure water at a pressure in the range of 10 to 30 kgf/cm². During this process, the specific resistance of the pure water was kept higher than 17 MΩ·cm. All the processing and fabrication was done in a clean room of class 100. The cavity was filled with methanol until just prior to installation in the standard test stand [7]. Figure 10 shows the cavity rinsing procedure.

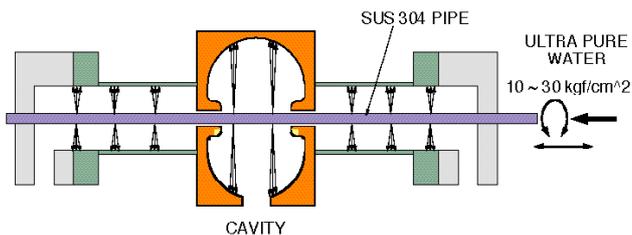


Fig. 10. Cavity rinsing procedure by high pressure ultra pure water.

The high gradient test was started at a base vacuum pressure of 8×10^{-11} Torr. In this experiment, the base vacuum pressure did not change greatly during rf processing at each power level except for an occasional rf breakdown. A maximum surface electrical field gradient of 334 MV/m was achieved which was limited by the klystron rf power available. Even at this level, the amount of peak dark current was 0.34 mA and a microscopic field enhancement factor of 37 was achieved.

DC electrodes. In the third experimental phase, the work went back to being a very basic study using DC electrodes to confirm the principles learned from the high gradient study and to prepare for the application of a very sensitive photo-cathode rf gun, such as a GaAs cathode. The electrode material was carefully chosen to be very high quality stainless steel SUS316L, because in general stainless is contaminated by oxide impurities such as dust particles during manufacture which is the main reason for dark current at high electrical surface gradients. Table 5 shows the specifications of clean (NK-clean-Z, SUS316L) and JIS standard SUS316L materials.

Table 5
Chemical compositions of SUS316L (%)

	C	Si	Mn	P	S	Ni	Cr	Mo
NK-clean-Z	0.004	0.12	0.27	0.001	0.0006	14.96	16.8	2.36
JIS-SUS316L	<0.03	<1.0	<2.0	<0.04	<0.03	12~16	16~18	2~3

The surface treatment and rinsing methods were also very important for obtaining a smooth and clean surface. Electro-mechanical polishing and warm pure water rinsing methods were selected. The surface roughness of the electrodes obtained from the lathe was less than 0.1 μm without pits on the surface. To avoid any contamination, the entire system of the DC high voltage test stand was fabricated in a class 1 clean room and pumped down to $\sim 4 \times 10^{-11}$ Torr after baking at 250 °C for 1 week. In the experiments, no field emission current was observed from the 1 cm gap electrodes at the -120 kV operating voltage, which corresponds to a surface electric field gradient of 11 MV/m. The maximum surface electric field gradient obtained was 34 MV/m at 88 pA of dark current from the 1 mm gap electrodes. At this level, the microscopic enhancement factor obtained was 40 from the F-N plot [8].

Conclusions

It is concluded that the magnitude of dark current depends on the cleanliness of the structure, and the maximum electrical field gradient is determined by the shape of the structure.

The general phenomena of dark current and breakdown are not strong frequency dependent from the DC and S-band frequency results.

However, multiple long structures operating at high frequency will necessitate more study. This study should be useful for the realization of a semiconductor photo-cathode rf gun.

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